Durable Neutral Color Anti-Reflective Coating for Mobile Displays

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An in-line PECVD (plasma enhanced chemical vapor deposition) process is used to deposit a high performance AR+DLC coating for cell phone and tablet displays (Figure 1). The coating is a 7 layer stack consisting of a 6 layer AR of alternating SiN and SiO₂ thin films and a DLC top coat. The use of SiN as the high index layer benefits not only overall durability, but the low dispersion of SiN widens the process window needed to maintain neutral color. The optical performance inclusive of the DLC is less than 0.70% reflectance from 450-650nm with the $a^*$, $b^*$ color range within +/-1.5 absolute value. Key characteristics of the PECVD process are long term process stability and uniformity, both critical to AR coating production. The high deposition rate allows a tool with one PECVD source per layer (more for the DLC) to produce 800km²/year making large quantity production of small displays practical. The experimental data and results for optical measurements and durability and environmental tests are presented.

Challenging Application

Every display - cell phones, tablets, laptops, TV’s - needs an anti-reflection (AR) coating. Uncoated glass reflects 8% of incoming light, (4% per side). This is what makes viewing so difficult in high ambient light conditions and degrades display color contrast. The use of sapphire for cover screens makes this worse. Sapphire has twice the light reflection of glass. In spite of the need - and the large market opportunity - AR coatings are not common on displays. The reasons for this are the application’s challenging environmental and durability specifications and the limitations of existing deposition technology.

Currently, AR coatings are made by either ion beam assisted deposition (IBAD), reactive sputtering or wet coating processes. IBAD can make quality AR films but mass production is not practical due to limits on batch size and cycle time. The IBAD process requires a large box coater and deposits successive layers using electron beam evaporation. The way the substrates are suspended and rotated over the evaporation sources limits the maximum substrate size to 0.1 m². A typical batch cycle exceeds 1 hour.

Reactive magnetron sputtering is scalable and capable of large volume production. However, as suggested by available sputtered AR products, maintaining absolute thickness uniformity is difficult. This is witnessed by the typical purple or green shading of these AR’s. This color bias is intentionally done to hide color variation caused by layer non-uniformity. Another challenge for reactive sputter is deposition rates are low so multiple cathodes are required for each layer. This exacerbates uniformity/stability issues and makes sputter systems large and expensive.

Wet coating is an attractive method to make AR’s due to the inherent low cost and high production volume of the process. While limited success has been achieved, the performance of these films remains below that of the thin film vacuum deposited films. This reduced performance includes both the optical AR properties and durability.

UltraDep™ Technology

General Plasma has developed a stable, high rate PECVD process for large area coating termed UltraDep™ [1]. In the process, the magnetically confined electrodes are hidden in a cavity and are not coated during a production run. The result is the PECVD process operates for days and weeks without process variation or loss of uniformity. Several patents have been granted and additional patents have been filed on both the process apparatus and method.

In addition to stable operation, UltraDep™ has other important features and benefits:

- Uniform deposition over large substrates to +/-1%
- Generation of an energetic ion flux to the substrate enables dense films on insulating substrates such as glass
- High deposition rate, 5-10x faster than reactive sputtering

Figure 2 shows an UltraDep™ PECVD module for 1 meter wide substrates.

Optical Performance

The UltraDep™ PECVD process is used to deposit a 7 layer stack consisting of a 6 layer AR film and a DLC coating (patents pending). The 6 layer AR coating is composed of alternating SiN and SiO₂ thin films. The optical performance of the complete stack is less than 0.70% reflectance over the visible spectrum (450-650nm) with the $a^*$ $b^*$ color within +/-1.5 absolute value (neutral color). Figure 3 shows the reflection & color performance for the coating.
Figure 3. Anti-reflective optical reflection spectrum

Figure 4 overlays reflectance curves from different runs over 5 days of production. As can be seen, coating reflectance variations are less than 0.1% at all visible wavelengths.

Figure 4. Anti-reflective optical reflection spectrum

The color of the AR coating is equally, if not more important than reflection performance. The ideal AR has a neutral color without a purple or green color bias. The AR+DLC coating achieves this ideal performance with $a^*$, $b^*$ color within +/-1.5 absolute value. Two aspects of the technology make a neutral color AR possible: 1) Dense, amorphous SiN can be deposited with a sufficiently high index (>1.9) film for the AR design. SiN has lower dispersion than TiO$_2$ and this widens the color process window, and 2) the PECVD process is uniform and stable. Uniformity is +/-1% and this uniformity is maintained for long periods as shown in Figure 4.

Figure 5. Scratch comparison between glass and AR+DLC coated glass using 1kg/in, 200 passes, 3M Green Scotch Brite.

The hydrophobicity of the film surface is equally durable. Using an automated scratch tester with 0000 steel wool covering a 1cm$^2$ “finger” and a 1kg weight, after more than 10,000 cycles the DLC coated AR stack shows no change in water contact angle (Figure 6).

Figure 6. Water contact angle before and after 10,500 pass scratch test

Beyond scratch testing, the complete AR+DLC stack demonstrates excellent hardness and durability. A selection of results are:

- Nano-indentation test measurement of 9.4 GPa. (Note that this is a measurement of the underlying SiN/SiO$_2$ AR only as the DLC is too thin to be detected by this test.) For reference, nano-indentation test measurement of Corning’s Gorilla glass 3 is 8.6 GPa [3].

- In the Erichson pencil test, the DLC+AR hardness was 4.0N vs. 0.3N typical of evaporated or sputtered AR coatings.

- Adhesion to the base glass and between film layers is excellent. Using standard grid/tape test methods, a 1mm square grid was cut into the stack to the substrate and a pull tape test done. The adhesion result met a 5B (no visible delamination) on the test scale. After this the sample, with the cut grid, was immersed in boiling water for 10 minutes and then the tape test was repeated. Again, no adhesion failure was seen. Finally, sample is immersed in salt bath (150mg pure NaCl in 600ml of DI water) at 80°C for 24 hours and the tape test was repeated. This series of tests, boiling a grid cut sample, is extremely aggressive. Any columnar film structure, excessive hydrogen or interlayer defects will cause delamination when exposed to these tests.

- After repeated and extended contact with cleaning agents such as IPA and acetone, no loss of adhesion or damage to coating occurs.

**Anti-Fingerprint Functionality**

DLC is hydrophobic and therefore a natural anti-fingerprint (AFP) coating. In testing, the water drop contact angle exceeds 90 degrees and the roll off angle is 15 degrees. Figure 7 shows an S4 phone half coated with the AR+DLC coating. Both halves of the screen were equally resistant than the native cover glass. Figure 5 compares the scratch resistance of chemically strengthened glass to GPI’s AR+DLC coated glass.

**Figure 7**
Durable Neutral Color Anti-Reflective Coating for Mobile Displays

continued from page 33

smudged before this photo was taken.

While the water contact angle is not as high as that of evaporated fluorocarbon layers, DLC AFP properties are durable and relatively insensitive to chemicals and solvents.

Figure 7. Anti-Fingerprint demonstration shows top side AR+DLC resists fingerprinting (top half right side coated with AR+DLC).

Conclusion
For the first time a durable AR+DLC coating is available for cell phones, tablets and other displays. The AR performance, neutral color appearance and exceptional durability meet and exceed the tough requirements for mobile displays. A new in-line PECVD process, makes this coating possible and meets industry requirements for high volume/low cost manufacturing.

References

Authors
John Madocks
John founded General Plasma 17 years ago and has over 30 years of experience in the vacuum coating industry. He has invented several new plasma sources and has issued and pending patents for improvements to ion sources and sputter cathodes. Most notably John has pioneered the use of plasma enhanced chemical vapor deposition (PECVD) for large area substrates.

John is passionate about engineering and loves the challenge of product design. His drive for excellence has made General Plasma an innovation leader in the industry. These days he is excited about General Plasma’s progress in in-line PECVD, making films like the AR+DLC presented in this article. John earned his BS in Mechanical Engineering from the California Polytechnic State University at San Luis Obispo in 1981.

Phong Ngo
Phong joined General Plasma in 2006 after finishing his Electrical Engineering degree at University of Arizona. At General Plasma, Phong designed the electrical controls and software for a wide variety of vacuum equipment ranging from reactive sputtering controllers to glass coating production systems. In the last 2 years, Phong expanded his contribution to include thin film process development as the leader of General Plasma’s R&D group. In this role he has been the creative force behind the PECVD process advancements that make the AR and DLC coatings presented in this article possible.

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